# Low-Gain Avalanche Diodes (LGAD) for photon science

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# **Collaborations**

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#### **Structure of LGADs**

LGADs are Avalanche Diodes specifically tailored for the detection of mips in HEP For mips: if the substrate is thin (~ 50  $\mu$ m) and the gain is ~ 20  $\rightarrow$  signal is fast (~30 ps)

LGADs are 20-50um thick (only active volume!) as compared to hundreds of um of std strip/pixel sensors.

LGADs feature a p+-layer (gain layer) under the n+.

Depletion of the p+ gain layer creates intense Electric Field, high enough for electron impact ionization to occur. Hole impact ionization ~ 0

LGAD for low-penetrating particles

→ LGADs operate before BreakDown (linear region)

→ gain ~ few 10s

Amplification is needed to have a good S/N when reading-out fast.



#### LGAD for mips, X-rays

#### Waveforms



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#### High Frame rates possible

- 9keV X-rays
- 500MHz repetition rate of SSRL beam \_\_\_\_
- ~GHz bandwidth read-out
- Poor energy resolution due to multiplication noise



Z. Galloway, https://doi.org/10.1016/j.nima.2019.01.050

#### **Limits of LGADs**

Lateral dimensions of Gain layer must be much larger than thickness of substrate, for a uniform multiplication.

Dead volume (gain~1) extends within the implanted region of the gain layer:

→ pixels/strips (pitch ~ 100  $\mu$ m) with gain layer below the implant have a Fill Factor<<100% (Voltage dependent)

- → large pads are preferred (~ 1 mm); e.g., HGTD of ATLAS and MTD of CMS
- → 4D detector not possible!!!





A possible Solution: Closelyspaced electrodes can be put on the opposite of the wafer (**i-LGADS**, CNM Barcelona), but wafers must be thick to be

processed.

→ not possible to associate fasttime information on a per-pixel level!

#### **Towards a 4D detector**

## AC-LGAD

Modification of DC-LGAD, requires fine tuning of two implants (n-resistive • and gain layer). Fabricated @ BNL, FBK, HPK, CNM. •



# **Deep-Junction LGAD**

Process on going @ BNL DC-pads 2<sup>nd</sup> epi layer *n*<sup>++</sup> *n*<sup>+</sup> *g*ain layer - *p*<sup>+</sup> Substrate - *p*<sup>++</sup> 6

- Signal spreads to several AC-pads, making occupancy high (only low event rate possible)
- Signal sharing can be used to fit hit position and hit time. Need also reconstruction algorithms.
- Optimization of AC-metal shapes are under investigation (seems however that pitch/resolution ~10)
- Slow/small signals from thicker substrates may be beyond detection?
  - Position resolution given by pitch, as in std pixel/strip detector
  - Careful: Slightly smaller electric field in the gain region in-between pads,
  - need an epitaxial layer deposition after the junction is formed into the first wafer. Not standard process!!!
  - Compatible with thicker substrates

#### **CMOS read-outs**

In HEP, DC-LGADs are read-out by ALTIROC (Omega group, France), ETROC (FNAL).

ALTIROC can read-out also AC-coupled LGAD. If we use the fact that: **Pitch/\sigma\_x > 10, ASIC pixel may be large.** 

But generally speaking, hard to fit fast electronics in small pixels. Efforts on-gong:

- FCFD0 (FNAL) (
- Timespot (<u>https://web.infn.it/timespot/</u>), although for the read-out of 3D pixel sensors





## Summary

- LGADs have been developed for detection of mips in HEP.
- LGADs can have a  $\sigma_t$  < 30ps (for mips), once a few design rules are met
- While poor spectroscopic properties, good for fast detection of X-rays
- OK also for the detection of low-energy X-rays, but need to reverse the sign of the doping.
- Established technology: a few foundries (BNL, CNM, FBK, HPK) can do them
- If we want σ<sub>x</sub> ~ 100um, LGADs are not good enough and other LGADs families must be used (or developed): AC-LGADs, Deep-Junction ...work in progress
- CMOS read-out with small pixel pitch is challenging. Work in progress.

Back up



#### Signal shape in LGAD vs std diode



#### Static Electrical Characterization

#### BNL's LGADs :

- Leakage current as measured on diodes  $(gain=1) 1x1 mm^2 is ~ 10pA (1nA/cm^2)$
- Consistent from batch to batch
- Clearly current depends on gain layer dose, so does the breakdown voltage



1.5E+22

1.0E+22

5.0E+21

 $C^{-2}-V$ 

LGAD

Diode

CNM (Barcelona, Spain), FBK (Trento, Italy), Hamamatsu (Japan), IHEP-NDL (Beijng, China) are also producing LGADs.

#### Signal sharing in AC-LGAD

• signal is shared among several electrodes.

 $\rightarrow$  interpolation allows to enhance position/timing resolution.

- Since multiple electrodes see a mip, not the best choice in a high event rate environment. EIC is ok.
- Pitch/σ<sub>x</sub> > 10 (<u>https://arxiv.org/abs/2007.09528</u>)
- σ<sub>t</sub> ~ 35 ps.



TCT laser scan (measure of signal amplitude as a function of the laser hit position)

Signal sharing



BNL AC-LGAD strip sensors, at pitch of 100, 150, 200 um. In a recent beamtest at FNAL:

1. σ<sub>x</sub><15um

3. 100% fill factor

#### AC-LGADs are the baseline for detectors in EIC Roman Pot



Also, consortium of 14 international institutes with interests in the LGAD technology for EIC detectors.

See Expression of Interest on "Fast timing silicon detectors for EIC detectors" <u>https://indico.bnl.gov/event/8552/contributions/43183/attachments/31235/49294/EI</u> <u>C.Eol\_LGAD\_consortium.pdf</u>

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